MAY-06-2005(FRI) 13:11

MANNAVA & KANG,

MAY 0 6 2005

(FAX)703 880 5270

P. 001/019

PATENT Atty Docket No.: 10004808-1

In The U.S. Patent and Trademark Office

In Re the Application of:

Inventor(s):

Osamu S. Nakagawa

Confirmation No.: 3635

Serial No.:

09/891,324

Examiner: Schillinger, Laura M.

Filed:

June 27, 2001

Group Art Unit:

Title:

PROCESS FOR HIGH-DIELECTRIC CONSTANT METAL-INSULATOR

METAL CAPACITOR IN VLSI MULTI-LEVEL METALIZATION SYSTEMS

MAIL STOP AF

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

CERTIFICATE OF FACSIMILE TO THE USPTO

I hereby certify that this correspondence is being transmitted to the Patent and Trademark Office facsimile number (703) 872-9306 on May 6, 2005. This correspondence contains the following document(s):

1 shoot of Transmittal Letter for Response/Amendment. (2 copies).

16 sheets of Request for Reconsideration.

Respectfully submitted,

MANNAVA & KANG, P.C.

On May 6, 2005

Timothy B. Kang

Reg. No.: 46,423

MANNAVA & KANG, P.C. 8221 Old Courthouse Road

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Vienna, VA 22182

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PATENT APPLICATION

Intellectual Property Administration P. O. Box 272400 Fort Cettins, Colorado 80527-2400

ATTORNEY DOCKET NO. 10004808-1

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

inventor(s):

Osamu S. Nakagawa

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Examiner: Schillinger, Laura

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\$360

4TH MONTH

\$1590,00

OTHER FEES

Filing Date:

June 27, 2001

Group Art Unit: 2813

Title:

PROCESS FOR HIGH-DIELECTRIC CONSTANT METAL-INSULATOR METAL CAPACITOR

IN VLSI MULTI-LEVEL METALIZATION SYSTEMS

] FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM

2ND MONTH

\$450.00

1ST MONTH

\$120,00

Mail Stop AF Commissioner For Patents PO Box 1450 Alexandria, VA 22313-1450

TRANSMITTAL LETTER FOR RESPONSE/AMENDMENT

Sir:												
	smitted he	erewith is/are the fo	llowina in	the above-identified	application	ո:						
(X) () (X)	Response	e/Amendment as calculated below		()	Petition	Petition to extend time to respond Supplemental Declaration						
()	Other: _	· .					(fee \$_					
Γ	CLAIMS AS AMENDED BY OTHER THAN A SMALL ENTITY											
	(1) FOR	(2) CLAIMS REMAINING AFTER AMENDMENT	(3) NUMBER EXTRA	(4) HIGHEST NUMBER PREVIOUSLY PAID FOR	(5) PRESENT EXTRA		(6) RATE	(7) ADDITIONAL FEES				
ľ	Total Claims	13	MINUS	20	= (×	\$50	\$	0			
	INDEP. CLAIMS	1	MINUS	3	= () x	\$200	\$	0			

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pursuant	to	37 CFR 1.2	25. A	dditional	ly please	charge any	fees	s to 1	Depos	it Acco	unt (08-2025	unde	r 37
CFR 1.16	3. 1	.17, 1.19,	1.20 a	ind 1.21.	. A duplic	ate copy of	this	she	et is e	nclosed				

Respectfully submitted,

3RD MONTH

\$1020,00

TOTAL ADDITIONAL FEE FOR THIS AMENDMENT

(X) I hereby certify that this paper is being transmitted to the Patent and Trademark Office facsimile	
number <u>(703) 872-9306</u> on <u>May 6, 2005</u>	_
Number of pages: 19	

Typed Name: Judy HyChung

Signature: MAIA

EXTENSION

FEE

Osamu S. Nakagawa

Timothy B. Kang

Attorney/Agent for Applicant(s)

Reg. No. 46,423

PATENT APPLICATION

Intellectual Property Administration P. O. Box 272400 Fort Collins, Colorado 80527-2400

ATTORNEY DOCKET NO. 10004808-1

IN THE

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Mail Stop AF Commissioner For Patents PO Box 1450 Alexandria, VA 22313-1450

TRANSMITTAL LETTER FOR RESPONSE/AMENDMENT

(X)	smitted herewith is/are the following in the a Response/Amendment)	- ~, 1	Petition to extend time to respond
(x) (x)	New fee as calculated below No additional fee	. ()	Supplemental Declaration
(`)	Other:			(fee \$
Γ	CLAIMS AS AMENDED	BY OTHER THAN	A S	MALL ENTITY

(1) FOR	(2) Claims remaining After Amendment	(3) NUMBER EXTRA	NUMBER HIGHEST NUMBER PRES			(5) PRESENT EXTRA		(8) ATE	ADD!	(7) TIONAL EES
TOTAL CLAIMS 13		MINUS	3		=	0	×	\$50 \$200	\$	0
		MINUS			=	0	x		\$	
[] FIR	ST PRESENTATION OF A	MULTIPLE	DEPENDENT	CLAIM	,		+	\$360	\$	0
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		*		•	:	o	THER	FEES	\$	
			TOTAL AL	DOITIONAL FE	E FOR	THIS A	MEND	MENT	\$	0

O to Deposit Account 08-2025. At any time during the pendency of this application, please charge any fees required or credit any overpayment to Deposit Account 08-2025 pursuant to 37 CFR 1.25. Additionally please charge any fees to Deposit Account 08-2025 under 37 CFR 1.16, 1.17, 1.19, 1.20 and 1.21. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

Osamu S. Nakagawa

(X) I hereby certify that this paper is being transmitted to the Patent and Trademark Office facsimile

number <u>(703) 872-9306</u> _ on ___M_{PV}_6_2005

Chung

Number of pages: 19

Typed Name: Signature

Timothy B. Kang

Attorney/Agent for Applicant(s)

Reg. No. 46,423

Date: May 6, 2005

HEWLETT-PACKARD COMPANY Intellectual Property Administration P.O. Box 272400

Fort Collins, Colorado 80527-2400

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Commissioner for Patents

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Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Sir:

Applicant respectfully submits this Request for Reconsideration in response to the Final Official Action mailed on March 8, 2005. Please find below a listing of all the pending claims for the convenience of the Examiner in considering this Request for Reconsideration. The Examiner is respectfully requested to consider the remarks following the listing of the pending claims.